

EAST Search History

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|--|-----------------|------------------|---------|------------------|
| S6 | 0 | (polysilicon adj gate adj electrode) with (protect\$ adj (layer or film)) with (wet adj etch\$6) | US-PGPUB; USPAT | OR | ON | 2007/05/08 10:44 |
| S7 | 114 | (polysilicon adj gate adj electrode) and (protect\$ adj (layer or film)) and (wet adj etch\$6) | US-PGPUB; USPAT | OR | ON | 2007/05/02 09:23 |
| S8 | 2 | (polysilicon adj gate adj electrode) same (protect\$ adj (layer or film)) same (wet adj etch\$6) | US-PGPUB; USPAT | OR | ON | 2005/06/07 09:10 |
| S9 | 0 | 438/257,583.ccls. and (polysilicon adj gate adj electrode) same (protect\$ adj (layer or film)) same (wet adj etch\$6) | US-PGPUB; USPAT | OR | ON | 2005/06/07 09:10 |
| S10 | 0 | 438/257,583.ccls. and (polysilicon adj gate adj electrode) same (protect\$ adj (layer or film)) same (wet adj etch\$6) | US-PGPUB; USPAT | OR | ON | 2006/09/07 08:57 |
| S11 | 2 | 438/257,583.ccls. and (polysilicon adj gate adj electrode) and (protect\$ adj (layer or film)) and (wet adj etch\$6) | US-PGPUB; USPAT | OR | ON | 2005/06/07 09:10 |
| S12 | 2 | (polysilicon adj gate adj electrode) with (source and drain) with (((protect\$ or block\$6) adj (layer or film)) with (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/06/08 10:38 |
| S13 | 213 | (polysilicon adj gate adj electrode) and (source and drain) and (((protect\$ or block\$6) adj (layer or film)) and (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/06/08 10:50 |
| S18 | 39 | (polysilicon adj gate adj electrode) and (source and drain) and (((protect\$ or block\$6) adj (layer or film)) with (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/06/08 10:50 |
| S19 | 13 | (polysilicon adj gate adj electrode) and (source and drain) and (((protect\$ or block\$6) adj (layer or film)) near (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/06/08 10:59 |
| S20 | 76 | (polysilicon adj gate adj electrode) and (source and drain) and (((protect\$ or block\$6) adj (layer or film)) same (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/06/08 10:50 |
| S21 | 134 | (polysilicon adj gate adj electrode) and (source and drain) and (((protect\$ or block\$6 or mask\$6) adj (layer or film)) same (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/06/08 10:51 |

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| S22 | 75 | (polysilicon adj gate adj electrode) and (source and drain) and (((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/06/08 11:06 |
| S23 | 55 | (polysilicon adj gate adj electrode) and (source and drain) and (((protect\$ or block\$6 or masking) adj (layer or film)) with (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/06/08 11:03 |
| S24 | 75 | (polysilicon adj gate adj electrode) and (source and drain) and (((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) and @ad<="20040326" | US-PGPUB; USPAT | OR | ON | 2005/11/17 13:35 |
| S25 | 8 | ((("6800905") or ("6770516") or ("6768158") or ("6630388") or ("6525403") or ("6432829") or ("6642090") or ("6764884")).PN. | USPAT | OR | OFF | 2005/06/08 13:33 |
| S27 | 75 | (polysilicon adj gate adj electrode) and (source and drain) and (((((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) with (silicid\$6))) and @ad<="20040326" | US-PGPUB; USPAT | OR | ON | 2005/06/08 12:26 |
| S28 | 8 | ((polysilicon adj gate adj electrode) same (source and drain) same (((((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) with (silicid\$6))) and @ad<="20040326" | US-PGPUB; USPAT | OR | ON | 2005/06/08 12:27 |
| S29 | 2 | ((polysilicon adj gate adj electrode) with (source and drain) with (((((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) with (silicid\$6))) and @ad<="20040326" | US-PGPUB; USPAT | OR | ON | 2005/06/10 07:12 |
| S30 | 75 | ((polysilicon adj gate adj electrode) and (source and drain) and (((((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) with (silicid\$6))) and @ad<="20040326" | US-PGPUB; USPAT | OR | ON | 2005/06/08 12:27 |
| S31 | 2 | ((polysilicon adj gate adj electrode) with (source and drain) with (((((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) with (silicid\$6 or salicid\$6))) and @ad<="20040326" | US-PGPUB; USPAT | OR | ON | 2005/06/08 12:29 |

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| S32 | 8 | ((polysilicon adj gate adj electrode) same (source and drain) same (((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) with (silicid\$6 or salicid\$6))) and @ad<="20040326" | US-PGPUB; USPAT | OR | ON | 2005/06/08 12:29 |
| S33 | 16 | ((("6787854") or ("6642090") or ("6475890") or ("6472258") or ("6475869") or ("20020153587") or ("20020093053") or ("20020130354") or ("20020177263") or ("20030122186") or ("6583469") or ("6413802") or ("6225173") or ("6458662") or ("6300182") or ("5757038")).PN. | US-PGPUB; USPAT | OR | OFF | 2005/06/08 14:05 |
| S34 | 7 | ((("5462638") or ("5486282") or ("5796168") or ("5620611") or ("5937320") or ("6293457") or ("6468413")).PN. | US-PGPUB; USPAT | OR | OFF | 2005/06/08 14:56 |
| S94 | 1 | ("6489229").PN. | USPAT | OR | OFF | 2006/10/18 14:19 |
| S10 1 | 7 | ((("20050121748") or ("5323032") or ("5665616") or ("5599723")).PN. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/06/10 06:51 |
| S10 3 | 2 | ((((polysilicon adj gate adj electrode) and (source and drain)) with (((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) with (silicid\$6 or salicid\$6)) and @ad<="20040326" | US-PGPUB; USPAT | OR | ON | 2005/06/10 07:16 |
| S10 4 | 15 | ((((polysilicon adj gate adj electrode) and (source and drain)) with ((silicid\$6 or salicid\$6) adj gate)) and @ad<="20040326" | US-PGPUB; USPAT | OR | ON | 2005/06/10 07:21 |
| S10 5 | 99 | (438/583).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/06/10 07:22 |
| S10 6 | 1232 | (438/592).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/10/18 14:18 |

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| S10 7 | 485 | (438/649).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/06/10 07:23 |
| S10 8 | 132 | (438/651).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/06/10 07:23 |
| S10 9 | 1 | ("6140210").PN. | USPAT | OR | OFF | 2005/06/10 07:24 |
| S11 0 | 1 | ("20050215037").PN. | US-PGPUB | OR | OFF | 2007/05/02 09:08 |
| S11 1 | 7113 | ((gate or electrode) with (silicid\$4 or salicid\$4)) and ((source and drain) with (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/11/03 15:37 |
| S11 2 | 6910 | ((gate) with (silicid\$4 or salicid\$4)) and ((source and drain) with (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/11/03 15:37 |
| S11 3 | 6889 | ((gate) with (silicid\$4 or salicid\$4)) and ((source same drain) with (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/11/03 15:37 |
| S11 4 | 6185 | ((gate) with (silicid\$4 or salicid\$4)) and ((source near drain) with (silicide)) | US-PGPUB; USPAT | OR | ON | 2005/11/03 15:38 |
| S11 5 | 4891 | ((gate) with (silicid\$4 or salicid\$4)) and ((source near drain) with (silicide))) and polysilicon | US-PGPUB; USPAT | OR | ON | 2005/11/03 15:41 |
| S11 6 | 849 | ((gate) with (silicid\$4 or salicid\$4)) and ((source near drain) with (silicide))) and (silicid\$4 adj gate) | US-PGPUB; USPAT | OR | ON | 2005/11/04 09:58 |
| S11 7 | 592 | ((gate) with (silicid\$4 or salicid\$4)) and ((source near drain) with (silicide))) and (silicid\$4 adj gate) | USPAT | OR | ON | 2005/11/04 09:32 |
| S11 8 | 257 | ((gate) with (silicid\$4 or salicid\$4)) and ((source near drain) with (silicide))) and (silicid\$4 adj gate) | US-PGPUB | OR | ON | 2005/11/04 09:58 |
| S12 1 | 6 | ((("6821887") or ("6555453") or ("6096609")).PN. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/11/17 13:20 |

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| S12 2 | 9 | (polysilicon adj gate adj electrode) and (source and drain) and (((protect\$ or block\$6 or mask\$6) adj (layer or film)) with (silicide)) and @ad<="20040326" and (cobalt adj silicide) and (nickel adj silicide) | US-PGPUB; USPAT | OR | ON | 2006/05/02 18:50 |
| S12 8 | 4 | (polysilicon adj gate) and (source and drain) and (((protect\$ or block\$6 or mask\$6) adj (layer or film)) near (silicide)) and (silicid\$4 or salicid\$4) and @ad<="20040326" and (cobalt adj silicide) and (nickel adj silicide) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/05/02 18:56 |
| S12 9 | 208 | (polysilicon adj gate) and (source and drain) and (silicide adj (layer or film)) and (silicid\$4 or salicid\$4) and @ad<="20040326" and (cobalt adj silicide) and (nickel adj silicide) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/05/03 10:20 |
| S13 1 | 2585 | (gate or (gate adj electrode)) near silicide | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/05/03 10:19 |
| S13 2 | 2306 | (gate) near silicide | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/05/03 10:19 |
| S13 3 | 26 | (polysilicon adj gate) and (source and drain) and (silicide adj (layer or film)) and ((silicid\$4 or salicid\$4) adj (polysilicon adj gate)) and @ad<="20040326" and (cobalt adj silicide) and (nickel adj silicide) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/05/03 10:21 |
| S13 4 | 165 | (polysilicon adj gate) and (source and drain) and (silicide adj (layer or film)) and ((silicid\$4 or salicid\$4) adj (polysilicon adj gate)) and @ad<="20040326" | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/05/03 10:21 |
| S13 5 | 2 | ((("6514859") or ("6562718"))).PN. | USPAT | OR | OFF | 2006/05/11 08:43 |
| S13 6 | 4 | ((("20050215055") or ("6,864,178") or ("6,620,718") or ("6,830,987"))).PN. | US-PGPUB; USPAT | OR | OFF | 2006/05/11 09:45 |

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| S13 7 | 6 | ((("20050215055") or ("6,864,178") or ("6,620,718") or ("6,830,987") or ("6514859") or ("6562718"))).PN. | US-PGPUB; USPAT | OR | OFF | 2006/05/11 09:45 |
| S13 8 | 1980 | semiconductor and gate and source and drain and silicide and (silicid\$3 adj (gate or electrode)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/09/07 08:58 |
| S13 9 | 867 | semiconductor and (polysilicon adj (gate or electrode)) and source and drain and silicide and (silicid\$3 adj (gate or electrode)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/09/07 08:58 |
| S14 0 | 867 | semiconductor and (polysilicon adj (gate or electrode)) and source and drain and silicide and (silicid\$3 adj (gate or electrode)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/09/07 08:59 |
| S14 1 | 739 | semiconductor and (polysilicon adj (gate or electrode)) and source and drain and silicide and (silicid\$3 adj (gate or electrode)) and @ad<="20040326" | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/09/07 09:09 |
| S14 2 | 175 | semiconductor and (polysilicon adj (gate or electrode)) and source and drain and silicide and (silicid\$3 adj (gate or electrode)) and @ad<="20040326" and polycide | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/09/07 10:45 |
| S14 3 | 2202 | (438/656).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/10/18 14:18 |
| S14 4 | 769 | (438/683).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/10/18 14:18 |
| S14 5 | 135 | (257/e21.203).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/10/18 14:19 |

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| S14 6 | 3 | ((("6423634") or ("6376320") or ("6620718"))).PN. | USPAT | OR | OFF | 2006/10/18 14:20 |
| S14 7 | 4 | ((("6562718") or ("6562218") or ("20060022280") or ("20050260841"))).PN. | US-PGPUB; USPAT | OR | OFF | 2006/10/18 14:37 |
| S14 8 | 1795 | (438/655).CCLS. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2006/10/18 14:29 |
| S14 9 | 4 | ((("6,830,987") or ("6,514,859") or ("6,562,718") or ("6,620,718"))).PN. | US-PGPUB; USPAT | OR | OFF | 2006/10/18 14:38 |
| S15 0 | 2 | 10/884665 | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2007/05/04 13:33 |
| S15 2 | 2 | ("7157358").PN. | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/05/02 09:10 |
| S15 3 | 57 | (polysilicon adj (gate or electrode)) and (silicid\$4 adj (gate or electrode)) and (protect\$ adj (layer or film)) and (silicid\$4 adj (layer or film)) | US-PGPUB; USPAT | OR | ON | 2007/05/02 09:25 |
| S15 4 | 57 | (polysilicon adj (gate or electrode)) and (silicid\$4 adj (gate or electrode)) and (protect\$ adj (layer or film)) and (silicid\$4 adj (layer or film)) | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2007/05/02 09:26 |
| S15 5 | 5 | 10/810759 | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2007/05/04 14:00 |

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| S15 6 | 7 | ((("4866002") or ("6376342") or ("20020110986") or ("5780330"))).PN. | US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/05/04 14:05 |
| S15 7 | 4 | ((("6586332") or ("6555453") or ("6376320") or ("20020197805"))).PN. | US-PGPUB; USPAT | OR | OFF | 2007/05/08 10:24 |
| S16 2 | 6 | ((("6291890") or ("6146941") or ("6781189") or ("6878588") or ("6576649") or ("5293512"))).PN. | USPAT | OR | OFF | 2007/05/08 10:45 |
| S16 3 | 2 | 10/883818 | US-PGPUB; USPAT | OR | ON | 2007/05/08 10:45 |
| S16 4 | 1 | ("7049222").PN. | USPAT | OR | OFF | 2007/05/08 13:04 |
| S16 5 | 5 | ("5545581" "5989988" "6323103" "6388296" "6395598").PN. | US-PGPUB; USPAT; USOCR | OR | ON | 2007/05/08 10:48 |
| S16 6 | 1 | ("6531784").PN. | USPAT | OR | OFF | 2007/05/08 11:30 |